

	0	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	37	38	39	40	41	42	43	44	45	46	47	48	49	50	51	52	53	54	55	56	57	58	59	60	61	62	63	64	65	66	67	68	69	70	71	72	73	74	75	76	77	78	79	80	81	82	83	84	85	86	87	88	89	90	91	92	93	94	95	96	97	98	99
0	0	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	37	38	39	40	41	42	43	44	45	46	47	48	49	50	51	52	53	54	55	56	57	58	59	60	61	62	63	64	65	66	67	68	69	70	71	72	73	74	75	76	77	78	79	80	81	82	83	84	85	86	87	88	89	90	91	92	93	94	95	96	97	98	99

Inventor Two Given Name: Eiichi
Family Name: MURAKAMI
Postal Address Line One:
City of Residence: Tochigi
State or Province of Residence: Tochigi
Country of Residence: Japan
Citizenship Country: Japan

Correspondence Customer Number: 05514
Fax: (212) 218-2200

Title Line One: STOCKER, EXPOSURE APPARATUS, DEVICE MANUFACTURING
 Title Line Two: METHOD, SEMICONDUCTOR MANUFACTURING FACTORY, AND
 Title Line Three: EXPOSURE APPARATUS MAINTENANCE METHOD

Total Drawing Sheets: 10
Formal Drawings?: Yes
Application Type: Utility
Docket Number: 862.C2168
Secrecy Order in Parent Appl.: No

Representative Customer Number: 5514

Foreign Application One: 2000-094374
Filing Date: 03-30-2000
Country: JAPAN
Priority Claimed: Yes